

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	0	((wafer or substrate or objector reticle or mask) adj4 (stage or position\$4 or support\$4)) and strajector\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:45
S2	3044	((wafer or substrate or objector reticle or mask) adj4 (stage or position\$4 or support\$4)) and trajector\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:33
S3	116	S2 and ((wafer or substrate) near5 ( many or plurality) near5 (block or region or area))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:44
S4	55	S3 and ((data or information or characteristic) near9 (block or region or area))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:45
S5	32605	((wafer or substrate) near9 ( many or plurality) near9 (block or region or area))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:44
S6	8626	S5 and ((data or information or characteristic) near9 (block or region or area))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:45
S7	3193	S6 and ((wafer or substrate or objector reticle or mask) adj4 (stage or position\$4 or support\$4))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:46
S8	198	S7 and (((control\$4 or adjust\$4) near6 (movement or driv\$4 or moving or move) near8 (stage)) same (data or information or character\$7) same (block or region or area))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:55
S9	185	S8 and (\$lithograph\$4 or exposure)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 12:49

S10	73	S7 and (((control\$4 or adjust\$4) near6 (movement or driv\$4 or moving or move) near8 (stage)) same (accordanc or based) same (data or information or character\$7) same (block or region or area))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/14 13:18
S11	4	S10 and feedforward	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/14 13:18